Идеальная цилиндрическая оболочка: совершенная, но чувствительная к малы возмущения

Ideal Cylindrical Cloak: Perfect but Sensitive to Tiny Perturbations

Zhichao Ruan, Min Yan, Curtis W. Neff, and Min Qiu

Laboratory of Optics, Photonics and Quantum Electronics,
Department of Microelectronics and Applied Physics,
Royal Institute of Technology (KTH), Electrum 229, 16440 Kista, Sweden
Joint Research Center of Photonics of the
Royal Institute of Technology (Sweden) and Zhejiang University,
Zhejiang University, Yu-Quan, 310027 Hangzhou, People's Republic of China
e-mail: min@kth.se

Аннотация

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